

PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2004-235073

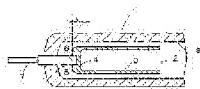
(43)Date of publication of application : 19.08.2004

(51)Int.CI. H01J 61/067

(21)Application number : 2003-023948 (71)Applicant : NEOMAX CO LTD

(22)Date of filing : 31.01.2003 (72)Inventor : SHIOMI KAZUHIRO
ISHIO MASAAKI
MATSUBARA SHIGEJI

(54) ELECTRODE ALLOY FOR FLUORESCENT DISCHARGE TUBE,
ELECTRODE FOR THE FLUORESCENT DISCHARGE TUBE AND
FLUORESCENT DISCHARGE TUBE PROVIDED WITH THE ELECTRODE



(57)Abstract:

PROBLEM TO BE SOLVED: To provide an electrode alloy for fluorescent discharge tube having a long service life of a lamp and which is superior in its moldability, an electrode for the fluorescent discharge tube and the fluorescent tube provided with the electrode.

SOLUTION: The electrode alloy for the fluorescent discharge tube is formed by Ni alloy, containing 1.0 to 3.0 mass% in total weight of one or two type(s) of elements selected from Nb or Ta, and the remainder substantially from Ni. The electrode for the fluorescent discharge tube 2 is provided with a tube part 3 with one end open and an end plate part 4, sealing the other end of the tube part 3. The end plate part 4 is formed thicker than the wall thickness of the tube part 3. A recessed part 6 for aligning a conductor for feeding power can be formed in a state concentric with the tube 3 in the end plate part 4.

LEGAL STATUS

[Date of request for examination] 05.10.2005

[Date of sending the examiner's
decision of rejection]

[Kind of final disposal of application
other than the examiner's decision of
rejection or application converted
registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's
decision of rejection]

[Date of requesting appeal against
examiner's decision of rejection]

[Date of extinction of right]

Copyright (C); 1998,2003 Japan Patent Office

* NOTICES *

**JPO and NCIPI are not responsible for any
damages caused by the use of this translation.**

1. This document has been translated by computer. So the translation may not reflect the original precisely.
2. **** shows the word which can not be translated.
3. In the drawings, any words are not translated.

CLAIMS

[Claim(s)]

[Claim 1]

The electrode alloy for the fluorescence discharge tubes with which one sort or two sorts of elements chosen from Nb and Ta are contained, and the total quantity of these elements is 1.0 - 3.0mass%, and becomes a remainder real target from nickel.

[Claim 2]

It is the electrode for the fluorescence discharge tubes with which it had the tube part from which the end was released, and the end plate section which blockades the other end of said tube part, and said tube part and end plate section were fabricated in one,

The electrode for the fluorescence discharge tubes with which the wall-thickness halfbeak of a tube part was also thickly formed for said end plate section.

[Claim 3]

Said end plate section is the electrode for the fluorescence discharge tubes indicated by claim 2 by which said tube part and the crevice for conductor positioning arranged concentrically were established in the outside.

[Claim 4]

The electrode for the fluorescence discharge tubes which is an electrode for the fluorescence discharge tubes indicated by claims 2 or 3, and was formed with the electrode alloy with which the electrode was indicated by claim 1.

[Claim 5]

It is the fluorescence discharge tube equipped with the electrode of a couple which the fluorescent screen was formed in the internal surface, has been arranged the glass tube with which the gas for discharge was enclosed with the interior, the conductor for feed closed by the both ends of the glass tube in the shape of penetration a glass tube, concentric, and within and without the glass tube, and inside said glass tube, and was connected to the edge of said conductor for feed,

The fluorescence discharge tube with which the electrode for the fluorescence discharge tubes indicated by any 1 term of claims 2-4 as said electrode was used, and joining of said conductor for feed was concentrically carried out to the outside of the end plate section of said electrode.

[Translation done.]

* NOTICES *

JPO and NCIPI are not responsible for any damages caused by the use of this translation.

1. This document has been translated by computer. So the translation may not reflect the original precisely.
2. **** shows the word which can not be translated.
3. In the drawings, any words are not translated.

DETAILED DESCRIPTION

[Detailed Description of the Invention]

[0001]

[The technical field to which invention belongs]

This invention relates to the fluorescence discharge tube used as a back light of

liquid crystal, its electrode, and electrode material.

[0002]

[Description of the Prior Art]

The fluorescence discharge tube small as a back light is used for liquid crystal equipment. The fluorescent screen (graphic display abbreviation) was formed in the internal surface, and this fluorescence discharge tube is equipped with the glass tube 11 with which the gas for discharge (rare gas and mercury vapour, such as argon gas) was enclosed with the interior, and the electrode 12 which constitutes the cold cathode of the couple prepared in the both ends of the glass tube 11, as shown in drawing 3 . Said electrode 12 is formed in one in the shape of a cylinder like object with base of the tubed tube part 13 from which the end was released, and the end plate section 14 which blockades the other end of this tube part 13. The end of the conductor 15 of the shape of a rod closed so that the edge of said glass tube 11 might be penetrated is welded to said end plate section 14, and lead wire 17 is connected to the other end of this conductor 15.

[0003]

Said electrode 12 is conventionally formed with pure nickel, and the size is [which has a small back light etc.] for the fluorescence discharge tubes about 0.1mm in the bore of about 1.5mm, the overall length of about 5mm, and thickness of a wall 13, for example. This tubed electrode is fabricated in one by carrying out deep-drawing shaping of the pure nickel sheet metal which usually has thickness equivalent to the thickness of said tube part.

[0004]

Although the electrode for the fluorescence discharge tubes had the good moldability and it was formed with pure nickel stable also in construction material as above-mentioned, there is a problem that a lamp life is comparatively short. That is, the phenomenon (sputtering) which ion etc. collides and emits an atom to an electrode from an electrode metal produces the fluorescence discharge tube in the case of burning. It combines with the mercury enclosed in the glass tube, and the atom of the electrode metal emitted by this sputtering exhausts the

mercury vapour in a glass tube. Conventionally, nickel which forms an electrode metal has many atomic burst sizes in the case of a spatter, i.e., a sputtering yield is high, and since consumption of mercury is large, it has the problem that the life of the discharge tube tends to fall.

[0005]

For this reason, to form an electrode with Nb, Ti, low Ta, or these low alloys of a sputtering yield is tried as indicated by JP,2002-110085,A (patent reference 1) in recent years.

[Patent reference 1]

JP,2000-3973,A (claim)

[0006]

[Problem(s) to be Solved by the Invention]

However, since these metallic elements are ingredients with which it is expensive with ingredients and high-melting tends [further] to oxidize as compared with nickel, even if it faces the manufacture, they need to manufacture bulk material by different special approaches from usual dissolution and casting, such as a plasma-arc-melting method and powder-metallurgy processing. Moreover, although spinning can be performed to the sheet metal about Nb, it is necessary to repeat and carry out the thinning of nonoxidizing-atmosphere annealing, such as vacuum annealing, and the rolling on the occasion of rolling of bulk material.

Thus, when manufacturing a small tubed electrode generally, Nb, Ta, etc. are inferior to fabricating-operation nature, and have the problem that a manufacturing cost becomes very high.

Moreover, since the end plate section has only thickness equivalent to a tubed body, the conventional tubed electrode has a severe welding condition at the time of welding the conductor for feed, and poor joining tends to produce it. For this reason, the electric and thermal junction to an electrode becomes uncertain, a discharge condition and a heat dissipation condition become unstable, and there is a problem that the lamp life of the fluorescence discharge tube falls.

This invention was made in view of this problem, its lamp life is long as compared

with nickel electrode, and it aims at offering the electrode alloy for the fluorescence discharge tubes which was moreover excellent in fabricating-operation nature and offering the electrode for the fluorescence discharge tubes which can prevent lowering of the lamp life resulting from poor joining of the conductor for feed, and offering the fluorescence discharge tube further equipped with the above-mentioned description.

[0007]

[Means for Solving the Problem]

one sort or two sorts of elements with which the electrode alloy for the fluorescence discharge tubes by this invention is chosen from Nb and Ta -- the total quantity -- 1.0 - 3.0mass% -- containing -- the remainder -- it is formed with the nickel-Nb alloy, nickel-Ta alloy, or nickel-Nb-Ta alloy which consists of nickel substantially.

[0008]

this electrode alloy -- Nb and/or Ta -- the total quantity -- 1.0 - 3.0mass%, since it is nickel alloy to contain Although a sputtering yield becomes a little high as compared with the case where an electrode is formed, only by low Nb of a sputtering yield, and Ta and the addition of Nb and Ta is very little With conventional pure nickel, as compared with the case where an electrode is formed, a sputtering yield can be reduced substantially, and a lamp life can be raised substantially. and -- since it has the fabricating-operation nature which does not have inferiority in the same dissolution and fluidity list as the case of pure nickel practically to pure nickel, without it uses plasma arc melting and vacuum annealing -- a small tubed electrode -- easy -- draw forming -- the closed flange between the colds (impact shaping) can be carried out, and it excels in productivity.

[0009]

Moreover, the electrode for the fluorescence discharge tubes by this invention is equipped with the tube part from which the end was released, and the end plate section which blockades the other end of said tube part, said tube part and end

plate section are fabricated in one, and the wall-thickness halfbeak of a tube part is also thickly formed for said end plate section.

[0010]

Since according to this electrode the thickness of the end plate section to which joining of the conductor for feed is carried out is formed more thickly than the thickness of the tube wall of a tube part even if it is the case that the thickness of the tube wall of a tube part is thin In case the edge of said conductor is end plate welded in the shape of comparison, the edge of a conductor can be end plate welded easily, without performing delicate control of joining outputs, such as a welding output, and both poor joining can be prevented. For this reason, the electric and thermal junction to a conductor and an electrode can become certain, a discharge condition and a heat dissipation condition can be stabilized, and lowering of the lamp life of the fluorescence discharge tube can be prevented, and the manufacture yield of the fluorescence discharge tube can be raised.

[0011]

In said electrode, it is desirable to establish said tube part and the crevice for conductor positioning arranged concentrically in the outside of said end plate section. By preparing this crevice for conductor positioning, a conductor can certainly be concentrically end plate welded [of an electrode] only by inserting the edge of a conductor in said crevice and welding it. For this reason, by closing a conductor concentrically at the edge of a glass tube, an electrode and a glass tube can be arranged concentrically, the homogeneity of the discharge condition in a glass tube and stability can improve, and a lamp life can be raised more.

[0012]

Moreover, as for said electrode, it is desirable to form with the alloy for electrodes concerning above-mentioned this invention. A lamp life can be raised according to an operation of Nb and Ta which could really fabricate by the fabricating-operation nature which was excellent in the electrode alloy, and were added slightly.

[0013]

Moreover, the glass tube with which, as for the fluorescence discharge tube by this invention, the fluorescent screen was formed in the internal surface, and the gas for discharge was enclosed with the interior, The conductor for feed closed by the both ends of the glass tube in the shape of penetration a glass tube, concentric, and within and without the glass tube, It is arranged inside said glass tube, the electrode for the fluorescence discharge tubes which is the fluorescence discharge tube equipped with the electrode of a couple connected to the edge of said conductor for feed, and is built over above-mentioned this invention as said electrode is used, and joining of said conductor for feed is concentrically carried out to the outside of the end plate section of said electrode. According to this fluorescence discharge tube, it has each effectiveness by the electrode concerning above-mentioned this invention.

[0014]

[Embodiment of the Invention]

the electrode alloy of this invention -- as an alloy element -- the element of either Nb and Ta -- 1.0 - 3.0mass% -- containing -- or those elements -- compounding -- the total quantity -- 1.0 - 3.0mass% -- it contains and is formed with the nickel-Nb alloy, nickel-Ta alloy, or nickel-Nb-Ta alloy (nickel alloy containing these Nb(s) and Ta may only be hereafter called nickel alloy) which consists of the remainder nickel and an unescapable impurity.

[0015]

When this invention person inquired wholeheartedly, Nb and Ta carried out the knowledge of a sputtering yield falling substantially, without only carrying out little addition at nickel, and degrading most of a moldability and workability. These elements are independent, or when compounding and adding, and large improvement in a lamp life cannot be desired. [in addition below 1.0mass%] [falling / of a sputtering yield / one sort or two sorts of total quantities] [too little] On the other hand, if the total quantity exceeds 3.0mass(es)% , a moldability and workability will deteriorate and impact shaping will become difficult. for this reason, the minimum of the total quantity -- 1.0mass(es)% -- desirable --

1.5mass(es)% -- carrying out -- that upper limit -- 3.0mass(es)% -- it may be 2.5mass(es)% preferably. In addition, the Ta of the reduction effectiveness of a sputtering yield is larger than Nb so that clearly from the below-mentioned example.

[0016]

Although said electrode alloy contains a high-melting difficulty workability element, after it hot-rolls the casting piece under atmospheric air after casting it under atmospheric air, since it is extremely excellent in a moldability and workability and anneals it under an inert atmosphere like pure nickel if needed, it is easily processible into an about 0.1mm sheet by cold-rolling. And after carrying out finish annealing (softening) if needed, a tubed electrode can be manufactured by carrying out draw forming of said sheet. Moreover, after processing a casting piece into a bar with hot rolling or hot forging, carrying out wire drawing of this, cutting the obtained wire rod to proper die length, obtaining a minor-axis-like raw material (it is called a slag.) and carrying out finish annealing if needed, a tubed electrode can be obtained by carrying out impact shaping (closed flange between the colds) of this. When carrying out impact shaping, board thickness of the end plate section of a tubed electrode can be easily thickened as compared with a tubed part, the crevice for conductor positioning can really be easily fabricated in the end plate section further again, and it excels in productivity. in addition, finish annealing -- about 800-950 degrees C -- 3min from -- what is necessary is just to carry out 3hr extent maintenance Since an annealing ambient atmosphere tends to oxidize and nitride Nb and Ta, it is desirable to carry out in inert gas ambient atmospheres, such as a vacuum ambient atmosphere or Ar.

[0017]

Next, the fluorescence discharge tube concerning the operation gestalt of this invention and its electrode are explained. Drawing 1 is the important section sectional view of the fluorescence discharge tube concerning an operation gestalt, the fluorescent screen 8 was formed in the internal surface, and this fluorescence discharge tube is equipped with the glass tube 1 with which the gas

for discharge (rare gas and mercury vapour, such as argon gas) was enclosed, and the electrode 2 which constitutes the cold cathode of the couple prepared in the both ends of that glass tube 1.

[0018]

Said electrode 2 is formed in [the tube part 3 from which the end was released, and the end plate section 4 which blockades the end of this tube part 3] one. The crevice 6 for conductor positioning where fitting of the end of said conductor 5 is carried out is formed in said end plate section 4 so that rod-like the conductor 5 and said tube part 3 for feed may be arranged concentrically. Said conductor 5 is closed so that the edge of a glass tube 1 may be penetrated in and abroad, fitting of the edge inside a glass tube 1 is carried out to said crevice 6, and joining is carried out by laser welding, resistance welding, soldering, etc. in the boundary periphery section with the end plate section 4. The lead wire 7 for feed is connected to the other end of said conductor 5 located in the outside of said glass tube 1.

[0019]

While the thickness (thickness [of the part where joining of the conductor 5 is carried out] t) of said end plate section 4 forms said crevice 6, the thick twist of the tube wall of said tube part 3 is also thickly formed so that a conductor 5 can be end plate welded [4] enough. In the small fluorescence discharge tube, the thickness of about 4-10mm and a tube part 3 is formed in about 0.08-0.2mm for the die length of an electrode 2, and the thickness of said end plate section 4 is formed in about 3 to 10 thick times of said tube part 3. In addition, the depth of the crevice 6 in the end plate section 4 is preferably good to make it into twice [more than] tube wall thickness more than the tube wall thickness of a tube part 3, and there should just be thickness of the base of a crevice 6 and a tube part side inner surface more than thick extent of a tube wall.

[0020]

Although said electrode 2 can be formed with pure nickel, forming with said nickel alloy is desirable. While having the cold-forming nature of pure nickel and

equivalent extent by using said nickel alloy, a sputtering yield can be greatly reduced as compared with pure nickel, and a lamp life can be raised. This tubed electrode is really fabricated by impact shaping.

[0021]

Although the above-mentioned operation gestalt showed the example in which the crevice 6 for conductor positioning was really fabricated by the end plate section 4, said crevice 6 is not necessarily needed. But since a conductor 5 and the tube part 3 of an electrode 2 are concentrically arranged by forming said crevice 6, by closing said conductor 5 concentrically to a glass tube 1, an electrode 2 and a glass tube 1 can be arranged easily concentrically, ununiformity-ization of a discharge condition can be prevented, and stabilization of discharge and improvement in a lamp life can be aimed at.

[0022]

Although an example is given and this invention is explained more concretely hereafter, this invention is not restrictively interpreted according to this example.

[0023]

[Example]

nickel alloy of the presentation shown in a table 1 was dissolved at 1500 degrees C with the vacuum induction furnace, after carrying out hot forging of the casting piece which cast the molten metal at 1100 degrees C in atmospheric air, it hot-rolled at the rolling initiation temperature of 1100 degrees C, and the hot-rolling plate and the hot-rolling wire rod were obtained. It was annealed in the mixed gas (atmospheric pressure) of nitrogen and hydrogen (it holds 2 hr at 900 degrees C), cold rolling and cold drawing were given, and these hot-rolling material was processed into the sheet metal which is 0.1mm of board thickness, and a wire rod with an outer diameter [phi] of 1.7mm. Workability and a sputtering yield were measured using these samples.

[0024]

Workability was evaluated by the impact shaping trial and the compression test about the nickel-Nb alloy. Moreover, the compression test result estimated the

impact moldability of a nickel-Ta alloy and a nickel-Nb-Ta alloy.

[0025]

The impact shaping trial cut said wire rod to the slag with a die length of 1.8mm, and was performed by fabricating actually a tubed electrode with bore 1.5mmphi shown in drawing 2 using this after finish annealing (it holds 2 hr at 900 degrees C under a vacuum ambient atmosphere), outer-diameter 1.7mmphi, an overall length [of 5.4mm], and a crevice depth [for conductor positioning] of 0.2mm. Punch of the used die is outer-diameter 1.5mmphi, 150 degrees of point aperture angles, and construction material die steel (SKD11). On the other hand, bores of a die are 1.7mmphi and construction material cemented carbide (D kind No. 6). since it is at the attainment event, and the die was damaged or punch deformed assessment of an impact moldability before the count of shaping reached 1000 shots or, the thing shaping became impossible cannot be fabricated for it -- when (x) and said shots per hour are reached, neither breakage of a die nor deformation of punch arises, but shaping of what was further able to be fabricated is possible -- it considered as (O).

[0026]

The compression test added the load of 1470MPa(s) (150kgf/mm²) to the shaft orientations of said slag, and asked for compressibility (%) by the following type. Compressibility = (slag die length after application of pressure)/(slag die length before application of pressure) x100

[0027]

Moreover, the sputtering yield was measured by the following points. nickel alloy sheet metal blank test piece (10mmx10mm) was extracted, and mirror polishing of the trial side was carried out. Using ion beam equipment (the product made from Veeco, type:VE-747), said test piece was used as the target, the electrical potential difference (500V) was impressed between the target and the substrate, the trial side was made to carry out an acceleration collision, and sputtering of the fixed time amount (30min) argon ion (1.3x10-6Torr) was carried out to it. The non-spatter section which masked a part of mirror plane is formed in the trial side,

and a level difference is formed in the boundary of the spatter section from which the mirror plane section of a test piece was deleted by sputtering after sputtering, and the masked non-spatter section. This level difference was measured using the contact process relative roughness meter (product [made from Sloan], and type:DEKTAK2A), and it asked for the sputtering yield (%) from the following formula.

Sputtering yield = level difference (A) / sputter time amount (30min) × 100
[0028]

The compressibility for which it asked as mentioned above, an impact moldability, and a sputtering yield are collectively shown in a table 1. In addition, for a comparison, the bulk material of pure nickel and pure Nb is prepared, and the sputtering yield for which it asked by carrying out sputtering on the same conditions as the above using this is also shown collectively.

[0029]

[A table 1]

試料 No.	組成 mass%			圧縮率 %	インパクト 成形性	スパッタ率 %	備 考
	N b	T a	N i				
1	0.5	—	残	52	○	200	比較例
2	1.0	—	残	53	○	190	発明例
3	1.5	—	残	54	○	182	"
4	2.0	—	残	55	○	172	"
5	4.0	—	残	60	×	166	比較例
6	6.0	—	残	65	×	167	"
7	—	1.0	残	53	(○)	125	発明例
8	—	2.0	残	55	(○)	101	"
9	1.0	1.0	残	55	(○)	157	"
11	100	—	—	—	—	149	比較例
12	—	—	100	—	—	214	"

[0030]

sample No. which has the amount of Nb(s) in this invention within the limits from a table 1 according to each sample of a nickel-Nb alloy 2, 3, and 4 (example of invention) are excellent in the impact moldability to a small tubed electrode, and its sputtering yield is pure -- to Nb, although it is high a little, even if it is 1.0 - 2.0%, and few additions, it turns out that it is falling 10% or more to pure nickel. Moreover, sample No. of a nickel-Ta alloy and a nickel-Nb-Ta alloy According to 7-9, the compressibility is 55% or less, and is sample No. From the relation between the compressibility of 1-6, and an impact moldability, the impact moldability which was excellent also in these samples is expectable. Moreover, it turns out that the sputtering yield is also falling greatly by addition of Ta.

[0031]

[Effect of the Invention]

Without making nickel contain Nb and Ta slightly with 1.0 - 3.0%, and spoiling the fabricating-operation nature to impact shaping etc. by slight content of Nb and Ta, every time the electrode alloy of this invention can raise a sputtering yield 10% or more and subtracts it as compared with pure nickel, it can improve a lamp life substantially. Moreover, since the thickness of the end plate section is formed more thickly than the tube wall thickness of a tube part, joining of the conductor for feed can become easy, the electric and thermal junction to an electrode can become certain, and a discharge condition and a heat dissipation condition can be stabilized by the electrode of this invention, and it can prevent lowering of the lamp life of the fluorescence discharge tube, and can raise the manufacture yield of the fluorescence discharge tube.

[Brief Description of the Drawings]

[Drawing 1] It is the important section sectional view of the fluorescence discharge tube equipped with the electrode for the fluorescence discharge tubes concerning the operation gestalt of this invention.

[Drawing 2] It is the sectional view of the electrode for the fluorescence discharge

tubes which carried out impact shaping in the example of this invention.

[Drawing 3] It is the important section sectional view of the fluorescence discharge tube equipped with the conventional electrode for the fluorescence discharge tubes.

[Description of Notations]

1 Glass Tube

2 Electrode

3 Tube Part

4 End Plate Section

5 Conductor

6 Crevice for Conductor Positioning

[Translation done.]

* NOTICES *

JPO and NCIPI are not responsible for any
damages caused by the use of this translation.

1. This document has been translated by computer. So the translation may not reflect the original precisely.
2. **** shows the word which can not be translated.
3. In the drawings, any words are not translated.

DESCRIPTION OF DRAWINGS

[Brief Description of the Drawings]

[Drawing 1] It is the important section sectional view of the fluorescence discharge tube equipped with the electrode for the fluorescence discharge tubes concerning the operation gestalt of this invention.

[Drawing 2] It is the sectional view of the electrode for the fluorescence discharge

tubes which carried out impact shaping in the example of this invention.

[Drawing 3] It is the important section sectional view of the fluorescence discharge tube equipped with the conventional electrode for the fluorescence discharge tubes.

[Description of Notations]

1 Glass Tube

2 Electrode

3 Tube Part

4 End Plate Section

5 Conductor

6 Crevice for Conductor Positioning

[Translation done.]

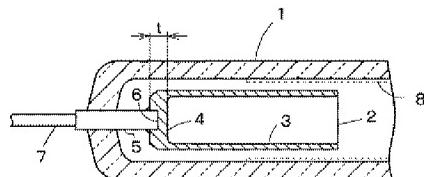
* NOTICES *

JPO and NCIPI are not responsible for any
damages caused by the use of this translation.

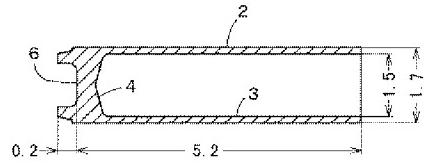
1. This document has been translated by computer. So the translation may not reflect the original precisely.
2. **** shows the word which can not be translated.
3. In the drawings, any words are not translated.

DRAWINGS

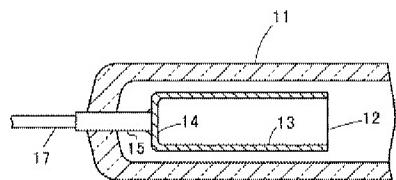
[Drawing 1]



[Drawing 2]



[Drawing 3]



[Translation done.]

(19) 日本国特許庁(JP)

(12) 公開特許公報(A)

(11) 特許出願公開番号

特開2004-235073

(P2004-235073A)

(43) 公開日 平成16年8月19日(2004.8.19)

(51) Int.Cl.⁷

H01J 61/067

F 1

H01J 61/067

テーマコード(参考)

L

5C015

審査請求 未請求 請求項の数 5 O L (全 8 頁)

(21) 出願番号

特願2003-23948 (P2003-23948)

(22) 出願日

平成15年1月31日 (2003.1.31)

(71) 出願人 000183417

株式会社NEOMAX

大阪府大阪市中央区北浜4丁目7番19号

(74) 代理人 100101395

弁理士 本田 ▲龍▼雄

塙見 和弘

大阪府吹田市南吹田2丁目19番1号 住友特殊金属株式会社吹田製作所内

(72) 発明者 石尾 雅昭

大阪府吹田市南吹田2丁目19番1号 住友特殊金属株式会社吹田製作所内

(72) 発明者 松原 茂次

大阪府吹田市南吹田2丁目19番1号 住友特殊金属株式会社吹田製作所内

F ターム(参考) 5C015 EE07

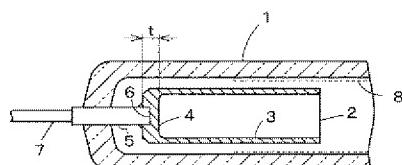
(54) 【発明の名称】 融光放電管用電極合金、融光放電管用電極およびその電極を備えた融光放電管

(57) 【要約】

【課題】 ランプ寿命が長く、成形加工性に優れた融光放電管用電極合金、融光放電管用電極、同電極を備えた融光放電管を提供する。

【解決手段】 本発明による融光放電管用電極合金は、NbおよびTaから選択される1種または2種の元素を合計量で1.0～3.0 mass%含有し、残部実質的にNiからなるNi合金によって形成される。本発明による融光放電管用電極2は、一端が解放された管部3と、前記管部3の他端を閉塞する端板部4とを備える。前記端板部4が管部3の管壁厚さよりも厚く形成される。前記端板部4には管部3と同心状に給電用導電体位置決め用凹部6を形成することができる。

【選択図】 図1



【特許請求の範囲】**【請求項1】**

NbおよびTaから選択される1種または2種の元素を含有し、これらの元素の合計量が1.0～3.0 mass%であり、残部実質的にNiからなる蛍光放電管用電極合金。

【請求項2】

一端が解放された管部と、前記管部の他端を閉塞する端板部とを備え、前記管部と端板部とが一体的に成形された蛍光放電管用電極であって、前記端板部が管部の管壁厚さよりも厚く形成された蛍光放電管用電極。

【請求項3】

前記端板部は、その外側に前記管部と同心状に配置された導電体位置決め用凹部が設けられた請求項2に記載された蛍光放電管用電極。

【請求項4】

請求項2または3に記載された蛍光放電管用電極であって、その電極が請求項1に記載された電極合金によって形成された蛍光放電管用電極。

【請求項5】

内壁面に蛍光膜が形成され、その内部に放電用ガスが封入されたガラス管と、そのガラス管の両端部にガラス管と同心状かつガラス管の内外に貫通状に封止された給電用導電体と、前記ガラス管の内部に配置され、前記給電用導電体の端部に接続された一対の電極を備えた蛍光放電管であって、前記電極として請求項2から4のいずれか1項に記載された蛍光放電管用電極が用いられ、前記電極の端板部の外側に前記給電用導電体が同心状に溶着された、蛍光放電管。

【発明の詳細な説明】**【0001】****【発明が属する技術分野】**

本発明は、例えば液晶のバックライトとして用いられる蛍光放電管、その電極および電極材に関する。

【0002】**【従来の技術】**

液晶装置にはバックライトとして小形の蛍光放電管が用いられる。かかる蛍光放電管は、図3に示すように、内壁面に蛍光膜（図示省略）が形成され、その内部に放電用ガス（アルゴンガス等の希ガスおよび水銀蒸気）が封入されたガラス管11と、そのガラス管11の両端部に設けられた一対の冷陰極を構成する電極12を備えている。前記電極12は、一端が解放された筒状の管部13と、この管部13の他端を閉塞する端板部14とによって有底筒状に一体的に形成されている。前記端板部14には前記ガラス管11の端部を貫通するように封止された棒状の導電体15の一端が溶接され、この導電体15の他端にリード線17が接続される。

【0003】

前記電極12は、従来、純Niによって形成され、そのサイズは、バックライト等の小形の蛍光放電管用のものでは、例えば内径1.5mm程度、全長5mm程度、壁部13の肉厚0.1mm程度である。かかる筒状電極は、通常、前記管部の肉厚と同等の厚さを有する純Ni薄板を深絞り成形することによって一体的に成形される。

【0004】

上記のとおり、蛍光放電管用電極は、成形性が良好で、材質的にも安定な純Niによって形成されていたが、ランプ寿命が比較的短いという問題がある。すなわち、蛍光放電管は点灯の際、電極にイオン等が衝突して電極金属から原子を放出する現象（スパッタリング）が生じる。このスパッタリングによって放出された電極金属の原子は、ガラス管内に封入された水銀と結合し、ガラス管内の水銀蒸気を消耗させる。従来、電極金属を形成するNiは、スパッタの際の原子放出量が多い、すなわちスパッタ率が高く、水銀の消耗が大きいため、放電管の寿命が低下しやすいという問題がある。

【0005】

このため、近年、特開2002-110085号公報（特許文献1）に記載されているように、電極をスパッタ率の低い、Nb、Ti、Ta又はこれらの合金で形成することが試みられている。

【特許文献1】

特開2000-3973号公報（特許請求の範囲）

【0006】

【発明が解決しようとする課題】

しかしながら、これらの金属元素はNiに比して高価であり、さらに高融点の酸化し易い材料であるため、その製造に際してもプラズマアーク溶解法や粉末冶金法など、通常の溶解・鋳造法とは異なる特殊な方法によってバルク材を製造する必要がある。また、Nbについてはその薄板に対して絞り加工を施すことができるものの、バルク材の圧延に際して真空焼純などの無酸化雰囲気焼純と圧延とを繰り返して薄肉化する必要がある。このように、Nb、Ta等は、総じて小形の筒状電極を製造する上で、成形加工性に劣り、製造コストが非常に高くなるという問題がある。

また、従来の筒状電極は端板部が筒状本体と同等の肉厚しかないため、給電用の導電体を溶接する際の溶接条件が厳しく、溶着不良が生じ易い。このため電極への電気的、熱的接合が不確実となり、放電状態、放熱状態が不安定となり、蛍光放電管のランプ寿命が低下するという問題がある。

本発明はかかる問題に鑑みなされたもので、Ni電極に比してランプ寿命が長く、しかも成形加工性に優れた蛍光放電管用電極合金を提供すること、また給電用導電体の溶着不良に起因するランプ寿命の低下を防止することができる蛍光放電管用電極を提供すること、さらに上記特徴を備えた蛍光放電管を提供することを目的とする。

【0007】

【課題を解決するための手段】

本発明による蛍光放電管用電極合金は、NbおよびTaから選択される1種または2種の元素を合計量で1.0～3.0mass%含有し、残部実質的にNiからなるNi-Nb合金、Ni-Ta合金あるいはNi-Nb-Ta合金によって形成される。

【0008】

この電極合金はNbおよび/またはTaを合計量で1.0～3.0mass%含有するNi合金であるので、スパッタ率の低いNb、Taのみによって電極を形成する場合に比してスパッタ率はやや高くなるものの、Nb、Taの添加量が極めて少量であるにもかかわらず、従来の純Niによって電極を形成する場合に比してスパッタ率を大幅に低下させることができ、ランプ寿命を大幅に向上させることができる。しかも、実用上、純Niの場合と同様の溶解・鋳造性並びに純Niに対して実用上遜色のない成形加工性を有するため、プラズマアーク溶解や真空焼純を用いることなく、小形の筒状電極に容易に絞り成形や冷間閉塞鍛造（インパクト成形）することができ、生産性に優れる。

【0009】

また、本発明による蛍光放電管用電極は、一端が解放された管部と、前記管部の他端を閉塞する端板部とを備え、前記管部と端板部とが一体的に成形され、前記端板部が管部の管壁厚さよりも厚く形成される。

【0010】

この電極によれば、管部の管壁の厚さが薄い場合であっても、給電用導電体が溶着される端板部の厚さが管部の管壁の厚さよりも厚く形成されるので、前記導電体の端部を端板部に突き合わせ状に溶着する際、溶接出力などの溶着出力の微妙な制御を行うことなく導電体の端部を端板部に容易に溶着することができ、両者の溶着不良を防止することができる。このため、導電体と電極との電気的、熱的接合が確実となり、放電状態、放熱状態が安定し、蛍光放電管のランプ寿命の低下を防止することができ、また蛍光放電管の製造歩留まりを向上させることができる。

【0011】

前記電極において、前記端板部の外側に前記管部と同心状に配置された導電体位置決め用

凹部を設けることが好ましい。かかる導電体位置決め用凹部を設けることによって、導電体の端部を前記凹部に差し込んで溶着するだけで、電極の端板部に導電体を同心状に確実に溶着することができる。このため、導電体をガラス管の端部に同心状に封止することにより、電極とガラス管とが同心状に配置され、ガラス管内における放電状態の均一性、安定性が向上し、ランプ寿命をより向上させることができる。

【0012】

また、前記電極は上記本発明に係る電極用合金で形成することが好ましい。その電極合金の優れた成形加工性によって一体成形することができ、また僅かに添加されたNb、Taの作用によりランプ寿命を向上させることができる。

【0013】

また、本発明による蛍光放電管は、内壁面に蛍光膜が形成され、その内部に放電用ガスが封入されたガラス管と、そのガラス管の両端部にガラス管と同心状かつガラス管の内外に貫通状に封止された給電用導電体と、前記ガラス管の内部に配置され、前記給電用導電体の端部に接続された一対の電極を備えた蛍光放電管であって、前記電極として上記本発明にかかる蛍光放電管用電極が用いられ、前記電極の端板部の外側に前記給電用導電体が同心状に溶着されたものである。この蛍光放電管によれば、上記本発明にかかる電極による各効果を備える。

【0014】

【発明の実施の形態】

本発明の電極合金は、合金元素としてNbおよびTaのいずれか一方の元素を1.0～3.0 mass%含有し、あるいはそれらの元素を複合して合計量で1.0～3.0 mass%含有し、残部Niおよび不可避的不純物からなるNi-Nb合金、Ni-Ta合金あるいはNi-Nb-Ta合金（以下、これらのNb、Taを含むNi合金を単にNi合金という場合がある。）によって形成される。

【0015】

本発明者が鋭意研究したところ、NbおよびTaは、Niに少量添加するだけで、成形性、加工性をほとんど劣化させることなく、スパッタ率が大幅に低下することを知見した。これらの元素は単独で、あるいは複合して添加する場合、1種または2種の合計量が1.0 mass%未満の添加では、スパッタ率の低下が過少となり、ランプ寿命の大幅な向上は望めない。一方、合計量が3.0 mass%を超えると成形性、加工性が劣化し、インパクト成形が困難になる。このため、合計量の下限を1.0 mass%、好ましくは1.5 mass%とし、その上限を3.0 mass%、好ましくは2.5 mass%とする。なお、後述の実施例から明らかなように、Taの方がNbよりもスパッタ率の低減効果は大きい。

【0016】

前記電極合金は、高融点の難加工性元素を含むものの、純Niと同様、成形性、加工性に極めて優れるので、大気下で鋳造した後、その鋳造片を大気下で熱間圧延し、必要に応じて不活性雰囲気下で焼鈍した後、冷間圧延することにより0.1mm程度のシートに容易に加工することができる。そして、必要に応じて仕上焼鈍（軟化焼鈍）した後、前記シートを絞り成形することによって、筒状電極を製造することができる。また、鋳造片を熱間圧延や熱間鍛造によって棒材に加工し、これを伸線し、得られた線材を適宜の長さに切断して短軸状素材（スラグという。）を得て、必要に応じて仕上焼鈍した後、これをインパクト成形（冷間閉塞鍛造）することによって筒状電極を得ることができる。インパクト成形する場合、筒状電極の端板部の板厚を筒状部に比して容易に厚くすることができ、さらにまた端板部に導電体位置決め用の凹部を容易に一体成形することができ、生産性に優れる。なお、仕上焼鈍は、800～950°C程度で3minから3hr程度保持すればよい。焼鈍雰囲気は、Nb、Taは酸化および窒化し易いので、真空雰囲気あるいはAr等の不活性ガス雰囲気中で行うことが好ましい。

【0017】

次に、本発明の実施形態にかかる蛍光放電管およびその電極について説明する。図1は、

実施形態にかかる蛍光放電管の要部断面図であり、この蛍光放電管は、内壁面に蛍光膜8が形成され、放電用ガス（アルゴンガス等の希ガスおよび水銀蒸気）が封入されたガラス管1と、そのガラス管1の両端部に設けられた一对の冷陰極を構成する電極2を備えている。

【0018】

前記電極2は、一端が解放された管部3と、この管部3の一端を閉塞する端板部4とが一体的に形成されている。前記端板部4には、給電用の棒状の導電体5と前記管部3とが同心状に配列されるように、前記導電体5の一端が嵌合される導電体位置決め用凹部6が形成されている。前記導電体5は、ガラス管1の端部を内外に貫通するように封止され、ガラス管1の内側の端部が前記凹部6に嵌合され、端板部4との境界外周部においてレーザ溶接、抵抗溶接、ろう付けなどによって溶着されている。前記ガラス管1の外側に位置する、前記導電体5の他端には給電用のリード線7が接続される。

【0019】

前記端板部4の厚さ（導電体5が溶着される部位の厚さt）は、前記凹部6を形成するとともに導電体5を端板部4に十分溶着することができるよう、前記管部3の管壁の肉厚よりも厚く形成されている。小形の蛍光放電管では、電極2の長さは4～10mm程度、管部3の肉厚は0.08～0.2mm程度に形成され、前記端板部4の厚さは前記管部3の肉厚の3～10倍程度に形成される。なお、端板部4における凹部6の深さは管部3の管壁厚さ以上、好ましくは管壁厚さの2倍以上とするのがよく、また凹部6の底面と管部側内面との肉厚は管壁の肉厚程度以上あればよい。

【0020】

前記電極2は、純Niで形成することができるが、前記Ni合金で形成することができる。前記Ni合金を用いることにより、純Niと同等程度の冷間成形性を有するとともに、スパッタ率を純Niに比して大きく低減することができ、ランプ寿命を向上させることができる。この筒状電極は、インパクト成形によって一体成形される。

【0021】

上記実施形態では、導電体位置決め用凹部6が端板部4に一体成形された例を示したが、前記凹部6は必ずしも必要としない。もっとも、前記凹部6を形成することによって、導電体5と電極2の管部3とが同心状に配置されるので、前記導電体5をガラス管1に同心状に封止することによって、電極2とガラス管1とを同心状に容易に配置することができ、放電状態の不均一化を防止することができ、放電の安定化、ランプ寿命の向上を図ることができる。

【0022】

以下、実施例を挙げて本発明をより具体的に説明するが、本発明はかかる実施例によって限定的に解釈されるものではない。

【0023】

【実施例】

表1に示す組成のNi合金を真空誘導炉にて1500°Cにて溶解し、その溶湯を鋳造した鋳造片を大気中で1100°Cで熱間鍛造した後、圧延開始温度1100°Cで熱間圧延を行い、熱延板および熱延線材を得た。これらの熱延材は窒素および水素の混合ガス（大気圧）中で焼鈍（900°Cで2hr保持）され、冷間圧延および冷間伸線が施され、板厚0.1mmの薄板、外径1.7mmの線材に加工された。これらの試料を用いて加工性およびスパッタ率が測定された。

【0024】

加工性は、Ni-Nb合金についてはインパクト成形試験および圧縮試験によって評価した。また、Ni-Ta合金、Ni-Nb-Ta合金のインパクト成形性については圧縮試験結果によって評価した。

【0025】

インパクト成形試験は、前記線材を1.8mmの長さのスラグに切断し、仕上焼鈍（真空雰囲気下、900°Cで2hr保持）後、これを用いて図2に示す、内径1.5mm、外

外径1.7mm ϕ 、全長5.4mm、導電体位置決め用凹部深さ0.2mmの筒状電極を実際に成形することによって行われた。用いた成形型のパンチは、外径1.5mm ϕ 、先端部開き角150°、材質ダイス鋼(SKD11)である。一方、ダイは、内径は1.7mm ϕ 、材質超硬合金(D種6号)である。インパクト成形性の評価は、成形回数が100ショットに到達する前あるいは到達時点でダイが破損し、あるいはパンチが変形したため、成形が出来なくなったものを成形不可(×)、前記ショット数に到達した時点でダイの破損やパンチの変形が生じず、さらに成形可能であったものを成形可能(○)とした。

【0026】

圧縮試験は、前記スラグの軸方向に1470MPa(150kgf/mm²)の荷重を付加し、下記式により圧縮率(%)を求めた。

$$\text{圧縮率} = (\text{加圧後のスラグ長さ}) / (\text{加圧前のスラグ長さ}) \times 100$$

【0027】

また、スパッタ率は以下の要領により測定された。Ni合金薄板から試験片(10mm×10mm)を採取し、試験面を鏡面研磨した。イオンビーム装置(Veeco社製、型式:VE-747)を用いて、前記試験片をターゲットとし、ターゲットと基板との間に電圧(500V)を印加し、一定時間(30min)アルゴンイオン(1.3×10^{-6} Torr)を試験面に加速衝突させ、スパッタリングした。試験面には鏡面の一部をマスキングした非スパッタ部が形成されており、スパッタリング後には、スパッタリングによって試験片の鏡面部が削られたスパッタ部とマスキングされた非スパッタ部との境界に段差が形成される。この段差を接触式粗度計(Sloan社製、型式:DEKTAKE2A)を用いて測定し、下記式からスパッタ率(%)を求めた。

$$\text{スパッタ率} = \text{段差}(\text{\AA}) / \text{スパッタ時間}(30\text{min}) \times 100$$

【0028】

以上のようにして求めた圧縮率、インパクト成形性、スパッタ率を表1に併せて示す。なお、比較のため、純Niおよび純Nbのバルク材を準備し、これを用いて上記と同様の条件でスパッタリングすることによって求めたスパッタ率も併せて示す。

【0029】

【表1】

試料 No.	組成 mass%			圧縮率 %	インパクト 成形性	スパッタ率 %	備 考
	Nb	Ta	Ni				
1	0.5	—	残	52	○	200	比較例
2	1.0	—	残	53	○	190	発明例
3	1.5	—	残	54	○	182	"
4	2.0	—	残	55	○	172	"
5	4.0	—	残	60	×	166	比較例
6	6.0	—	残	65	×	167	"
7	—	1.0	残	53	(○)	125	発明例
8	—	2.0	残	55	(○)	101	"
9	1.0	1.0	残	55	(○)	157	"
11	100	—	—	—	—	149	比較例
12	—	—	100	—	—	214	"

【0030】

表1より、Ni-Nb合金の各試料によると、Nb量が大発明範囲内にある試料Ni-Nb

2, 3および4（発明例）は、小形筒状電極に対するインパクト成形性に優れ、スパッタ率は純Nbに対して若干高いものの、1.0～2.0%と僅かな添加量であっても、純Niに対して10%以上低下していることが分かる。また、Ni-Ta合金、Ni-Nb-Ta合金の試料No. 7～9によると、その圧縮率は55%以下であり、試料No. 1～6の圧縮率とインパクト成形性との関係から、これらの試料においても優れたインパクト成形性を期待することができる。また、スパッタ率もTaの添加により大きく低下していることが分かる。

【0031】

【発明の効果】

本発明の電極合金は、NiにNb、Taを1.0～3.0%と僅かに含有させたものであり、Nb、Taの僅かな含有によりインパクト成形等に対する成形加工性を損なうことなく、純Niに比してスパッタ率を10%以上向上させることができ、引いてはランプ寿命を大幅に改善することができる。また、本発明の電極は、端板部の厚さが管部の管壁厚さより厚く形成されているので、給電用導電体の溶着が容易になり、電極への電気的、熱的接合が確実となり、放電状態、放熱状態が安定し、蛍光放電管のランプ寿命の低下を防止することができ、また蛍光放電管の製造歩留まりを向上させることができる。

【図面の簡単な説明】

【図1】本発明の実施形態にかかる蛍光放電管用電極を備えた蛍光放電管の要部断面図である。

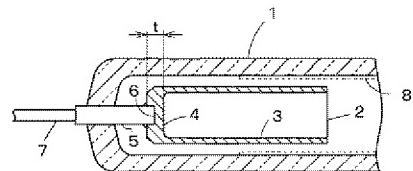
【図2】本発明の実施例においてインパクト成形した蛍光放電管用電極の断面図である。

【図3】従来の蛍光放電管用電極を備えた蛍光放電管の要部断面図である。

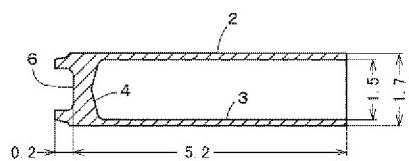
【符号の説明】

- 1 ガラス管
- 2 電極
- 3 管部
- 4 端板部
- 5 導電体
- 6 導電体位置決め用凹部

【図1】



【図2】



【図3】

